- Nanowire MOSFETs
 - Nonparabolicity
- CNT Bandstructure
 - •CNT FETs



1D InAs nanowires – subband separation << kT ~ 10 nm diameter Effective Mass:

$$E_{nm} = \frac{\hbar^2}{2m^*} \left(\frac{n^2}{W_Z^2} + \frac{m^2}{W_y^2} \right)$$

Nanowire MOSFET: Single Subband

$$n_{L}^{+} = \frac{1}{L} \sum_{k>0} f_{0} = \frac{N_{1D}}{2} F_{-\frac{1}{2}}(\eta_{F})$$

$$n_{L}^{-} = \frac{1}{L} \sum_{k>0} f_{0} = \frac{N_{1D}}{2} F_{-\frac{1}{2}}(\eta_{F} - U_{D})$$

$$I_{D}^{+} = \frac{1}{L} \sum_{k>0} v_{x} f_{0} = \frac{2qkT}{h} F_{0}(\eta_{F})$$

$$I_{D}^{-} = \frac{1}{L} \sum_{k>0} v_{x} f_{0} = \frac{2qkT}{h} F_{0}(\eta_{F} - U_{D})$$

$$v^{+}(0) = v_{T} \frac{F_{0}(\eta_{F})}{F_{-\frac{1}{2}}(\eta_{F})}$$

$$v^{-}(0) = v_{T} \frac{F_{0}(\eta_{F} - U_{D})}{F_{-\frac{1}{2}}(\eta_{F} - U_{D})}$$

$$D_{1D} = \frac{\sqrt{2m^*}}{\pi\hbar} \frac{1}{\sqrt{E - E_C}}$$

$$N_{1D} = \sqrt{\frac{2m^*kT}{\pi\hbar^2}}$$

$$v_T = \sqrt{\frac{2kT}{\pi m^*}}$$

$$C_{ox} = \frac{2\pi\varepsilon_{r}\varepsilon_{0}}{\ln\left(\frac{t_{ox} + r_{wire}}{r_{wire}}\right)}$$

Quantum Capacitance



Nanowire MOSFET – Degenerate conditions



A single subband InAs nanowire FET is operating very close to the ballistic limit!

Linear regime

$$I_{DS,lin} = \frac{2q^2}{h} V_{DS}$$

$$qV_{DS,sat} = \left[-\frac{\sqrt{(2m^{*})}q^{2}}{hC_{ox}} + \sqrt{\frac{2m^{*}q^{4}}{h^{2}C_{ox}^{2}}} + q(V_{GS} - V_{T}) \right]^{2}$$

$$I_{D,sat} = \frac{2q^{2}}{h}V_{DS,sat}$$

$$C_{q} = \frac{\sqrt{(2m^{*})}q^{2}}{\pi h}\frac{1}{\sqrt{qV_{DS,sat}}}$$
is
$$I_{D,sat} = \frac{2q^{2}}{h}\frac{C_{ox}}{C_{ox} + C_{q}}(V_{GS} - V_{T})$$
mit!
$$QCL \text{ Limit:} \quad I_{D,sat} = \frac{2q^{2}}{h}(V_{GS} - V_{T})$$
MOS Limit:
$$I_{D,sat} = \frac{h}{4\pi m^{*}}C_{ox}^{2}(V_{GS} - V_{T})^{2}$$

4qm





$$\Delta E = \langle \psi_{1,1} | U(x,y) | \psi_{1,1} \rangle = \frac{\{0.164 - 0.29\}}{\varepsilon_r \varepsilon_0} \frac{64W_1 W_2}{9\pi^2 (W_1^2 + W_1^2)} n_{1D}$$





Nonparabolicity



1D Channels – Carbon Nanotubes



Why CNTs?

Traditional bulk semiconductors:

Quantum Well/wire with surface roughness:

Mobility decreases as: $\mu_{eff} \propto L_w^6$

Strong assymetry between electron/hole effective masses

CNTs (& graphene, 2D materials): No 'dangling' bonds or surface reconstruction. Naturally atomically flat.

H. Sakaki, T. Noda, K. Hirakawa, M. Tanaka and T. Matsusue, Applied Physics Letters 51 (23), 1934-1936 (1987).



CNT formation & bandstructure



$$\hat{C} = \hat{a}_1 n + \hat{a}_2 m$$
$$d = \frac{\sqrt{3}a_{cc}}{\pi} \sqrt{n^2 + m^2 + nm}$$

Metallic if: (n-m) is a multiple of 3 Semiconductor otherwise

Armchair: (n,n) always metallic Zig-zag: (n,-n)=(n,0) Chiral: (n,m)

A CNT has a valley degeneracy = 2

$$E_{Gi} = \frac{2_{acc}t}{d} \times \frac{6i - 3 - (-1)^i}{4}$$

 $E(k) \approx \pm \frac{E_G}{2} \sqrt{1 + \left(\frac{3kd}{2}\right)^2}$

CNT bandstructure



Effect of nonparabolicity



Quantum capacitance: $C_q - DOS$ at E_F Ignoring band structure effects will underestimate C_q !